

Supporting information

POSS vapor phase grafting: a novel method to modify polymer film

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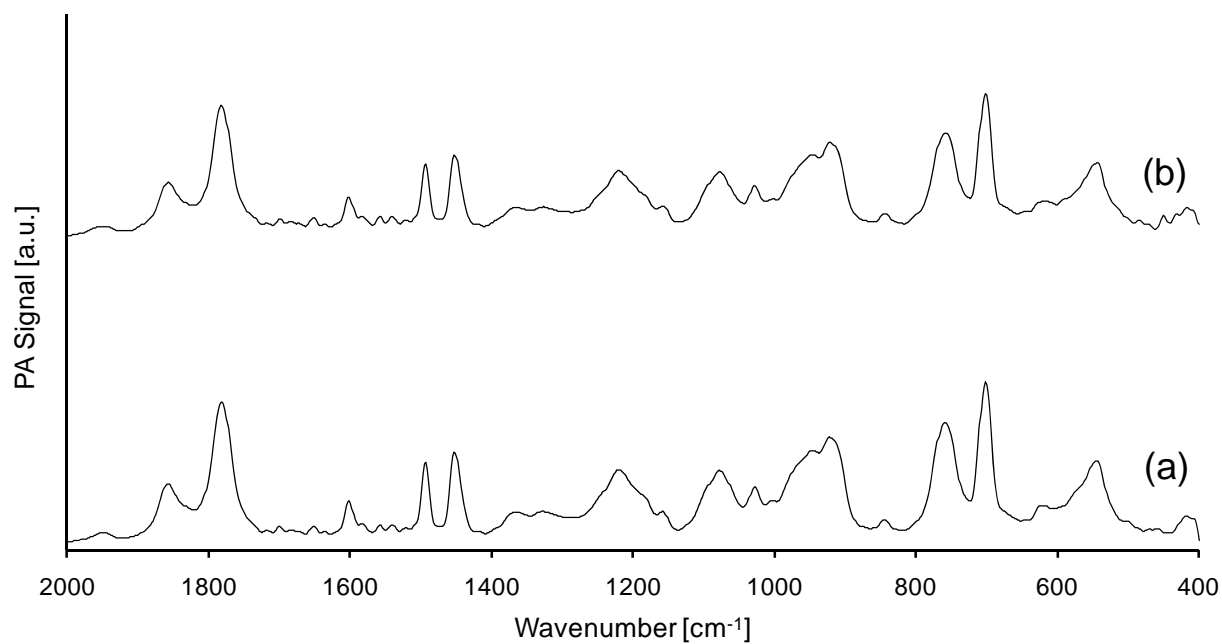


Fig S1 FT-IR spectra of: (a) PSMA/POSS180(30), (b) PSMA/POSS200(30)

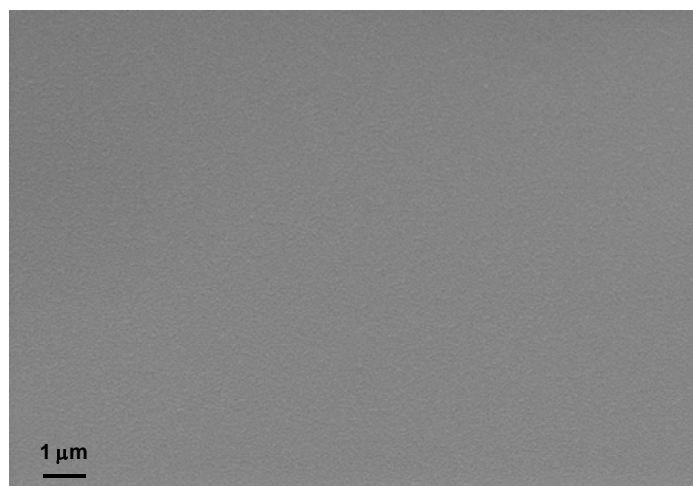


Fig S2 SEM micrograph by BS emission of the film PSMA/POSS-NH₂200(30) surface